

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Applicant:

Chris E. Barns et al.

Art Unit:

2822

Serial No.:

10/629,127

Examiner:

Khanh B. Duong

Filed:

July 29, 2003

For:

Preventing Silicide Formation at

the Gate Electrode in a Replacement

Metal Gate Technology

Docket:

ITL.1016US

P16703

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

## REPLY TO PAPER NO. 20040321

Sir:

In response to the office action mailed March 30, 2004, please amend the abovereferenced patent application as follows:

Date of Deposit: <u>June 3, 2004</u>
I hereby certify under 37 CFR 1.8(a) that this correspondence is being deposited with the United States Postal Service as first class mail with sufficient postage on the date indicated above and is addressed to the Commissioner for Patents, P.Q. Box 1450, Alexandria VA 22313-1450,

Cynthia (17 Hayden